

Upgraded Wafer Guide (Consumables) for 300mm Photo Resist Coat and Develop System

Application for

- TEL/Tokyo Electron Limited Lithius i, Lithius i+, Lithius Pro
- Sokudo RF3, RF3S, RF Duo
- TEL/Tokyo Electron Limited Clean Track ACT 12

Contents

1. Overview of Upgraded Wafer Guide

- 1) Current Issues/Problems of 300mm Photo Resist Coat and Develop System
- 2) Solutions

2. Product Details

3. Benefits and Performances



Note : Lithius and Clean Track Series is a trademark of TEL/Tokyo Electron Limited.

RF Series is a trademark of Sokudo Co., Ltd.

1. Overview

1) Current Issues/Problems of 300mm Wafer Guides

- A. Current Wafer Guide is easy to wear down due to Characteristics of 300m Wafers - Large and Heavy
- B. Wear-Down Wafer Guides causes Wafers Rebounding, Wafers Not properly settled down over the Guide. These Wafers would be broken or Process Failure while Transport and Spinning Process

2) Solutions

- A. We specially manufacture the Upgraded Wafer Guide with Special Tooling.

2. Product Details



Please contact us for more details.

3. Benefits and Performances

- 1) Upgraded Wafer Guide smoothly absorbs the contact shock of 300mm Wafer which is Large and Heavy
- 2) Upgraded Wafer Guide can have 300mm Wafer automatically and properly positioned on its Guide.
- 3) The Product Lifetime is enhanced at least 50% compared with OEM Wafer Guide.

Please contact info@justinbdnl.com to inquire more details.